

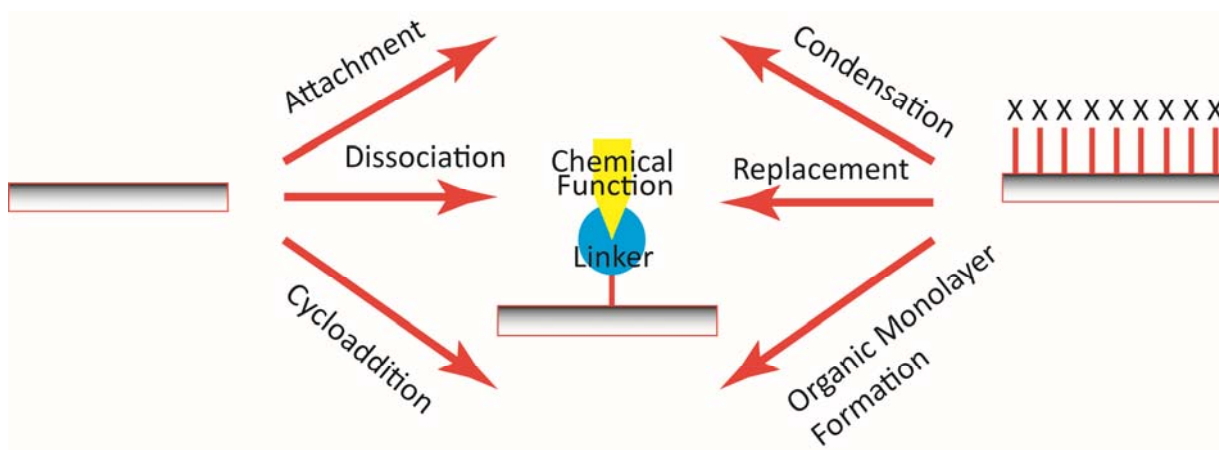
Challenges and Opportunities in Chemical Functionalization of Semiconductor Surfaces

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Graphical abstract



Highlights

We discuss recent developments and advances in semiconductor surface functionalization;

We outline the main approaches to chemical functionalization of semiconductors;

We discuss several pitfalls and possible trends in future applications of semiconductor surface functionalization

Abstract:

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